

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	4	(("5549995") or ("5700605") or ("20010001693") or ("6627359")).PN.	US-PGPUB; USPAT	OR	OFF	2006/05/06 09:43
L2	4221	((phas\$3 or shift\$3) near2 (mask or photomask or reticle) or PSM).ti,ab.	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 09:47
L3	762	2 and ((attenuat\$3 or halftone or half tone) with (phas\$3 or shift\$3 or PS or PSM) or attPSM or att PSM or HPSM or H PSM).ti,ab.	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 10:34
L4	205	3 and ((etch\$3 or groov\$3 or recess\$3 or mesa or rais\$3 or thick\$4) with (phas\$3 or shift\$3 or PS or PSM) or attPSM or att PSM or HPSM or H PSM).ti,ab.	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 09:49
L5	93	4 and ((blank or wavelength or wave length) with (phas\$3 or shift\$3 or mask or photomask or reticle or PS or PSM) or attPSM or att PSM or HPSM or H PSM).ti,ab.	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 09:50
L6	7976	430/5.ccls.	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 09:50
L7	412	216/12.ccls.	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 09:50
L8	50	4 and (6 or 7) not 5	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 09:53
L9	223	3 and (6 or 7) not 5 not 8	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 09:54
L10	11	9 and (reactive ion near2 etch\$3 or RIE) with ("SF.sub.6" or "CF.sub.4" or sulfur hexafluoride or carbon tetrafluoride)	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 10:00
L11	1	3 and (reactive ion near2 etch\$3 or RIE) with ("SF.sub.6" or "CF.sub.4" or sulfur hexafluoride or carbon tetrafluoride) not 5 not 8 not 10	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 10:02
L23	3	4 and ((blank or wavelength or wave length) with (phas\$3 or shift\$3 or mask or photomask or reticle or PS or PSM) or attPSM or att PSM or HPSM or H PSM) not 5 not 8 not 10 not 11	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 10:09

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L24	1	4 and ((second or third or plural or multiple) with (wavelength or wave length or thick\$4) same (phas\$3 or shift\$3 or mask or photomask or reticle or PS or PSM) or attPSM or att PSM or HPSM or H PSM).ti,ab. not 5 not 8 not 10 not 11 not 23	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 10:11
L25	4	4 and ((second or third or plural or multiple) same (wavelength or wave length or thick\$4) same (phas\$3 or shift\$3 or PSM) or attPSM or att PSM or HPSM or H PSM).ti,ab. not 5 not 8 not 10 not 11 not 23 not 24	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 10:12
L26	5	3 and ((second or third or plural or multiple) same (wavelength or wave length or thick\$4) same (phas\$3 or shift\$3 or PSM) or attPSM or att PSM or HPSM or H PSM).ti,ab. not 5 not 8 not 10 not 11 not 23 not 24 not 25	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 10:14
L27	117	3 and ((second or third or plural or multiple) same (wavelength or wave length or thick\$4) same (phas\$3 or shift\$3 or PSM) or attPSM or att PSM or HPSM or H PSM) not 5 not 8 not 10 not 11 not 23 not 24 not 25 not 26	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 11:00
L28	67	27 and ((transmi\$6 or transpar\$6) same ((attenuat\$3 or halftone or half tone) same (phas\$3 or shift\$3 or PSM)) or attPSM or att PSM or HPSM or H PSM).ti,ab.	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 10:16
L29	7	((Cheng Ming or ChengMing) near2 Lin).in. not 5 not 8 not 10 not 11 not 23 not 24 not 25 not 26 not 28	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 10:19
L30	511	(6 or 7) and (attenuat\$3 or halftone or half tone or semitranspar\$6 or semitransmi\$6 or semi (transpar\$6 or transmi\$6) or partial\$2 (transpar\$6 or transmi\$6) or attPSM or att PSM or HPSM or H PSM).ti,ab.	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 10:58
L31	20	30 and ((wavelength or wave length) and (thick\$4 or depth)).ti, ab.	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 11:02
L32	53	30 and (wavelength or wave length).ti,ab. not 31	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 11:04

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L33	131	30 and (transmit\$5 or transmis\$6 or transparen\$3) same (equation or expression or formula)	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 11:10
L34	143	30 and (phas\$3 or shift\$3 or PS) same (equation or expression or formula)	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 11:10
L35	105	33 and 34	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 11:12
L36	15	(mask or photomask or reticle or PSM) near3 blank same (different or other or another or plural or multiple) near3 (company or organization or corporation or enterprise or establishment or firm or outfit or crafter or business or fabricator or creator or builder or producer or assembler or manufacturer or maker or supplier)	US-PGPUB; USPAT; EPO; JPO	ADJ	ON	2006/05/06 11:27